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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/073,710	02/11/2002	Jes Asmussen	MSU 4.1-572	5422
21036	7590 05/04/2004	EXAMINER		
MCLEOD & MOYNE, P.C. 2190 COMMONS PARKWAY			FULLER, ERIC B	
OKEMOS, MI 48864			ART UNIT	PAPER NUMBER
			1762	
			DATE MAILED: 05/04/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

. ,		Application N	lo. Applic	ant(s)			
Office Action Summary		10/073,710	ASMUS	SSEN ET AL.			
		Examiner	Art Uni	it			
		Eric B Fuller	1762				
Period fo	The MAILING DATE of this commun or Reply	nication appears on the co	ver sheet with the correspo	ndence address			
THE - Exte after - If the - If NO - Failu Any	ORTENED STATUTORY PERIOD F MAILING DATE OF THIS COMMUN nsions of time may be available under the provision SIX (6) MONTHS from the mailing date of this com period for reply specified above is less than thirty (period for reply is specified above, the maximum s re to reply within the set or extended period for repl reply received by the Office later than three months ed patent term adjustment. See 37 CFR 1.704(b).	IICATION. s of 37 CFR 1.136(a). In no event, hunication. 30) days, a reply within the statutory tatutory period will apply and will exty will, by statute, cause the application.	nowever, may a reply be timely filed minimum of thirty (30) days will be co bire SIX (6) MONTHS from the mailing on to become ABANDONED (35 U.S.	nsidered timely. date of this communication. C. § 133).			
Status							
1)⊠	Responsive to communication(s) fil	ed on <u>01 <i>April 2004</i></u> .					
2a) <u></u>	This action is FINAL .	2b)⊠ This action is non-	final.				
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposit	ion of Claims						
5)□ 6)⊠ 7)□	Claim(s) 1-18 is/are pending in the 4a) Of the above claim(s) 6 and 7 is Claim(s) is/are allowed. Claim(s) 1-5 and 8-18 is/are rejected claim(s) is/are objected to. Claim(s) are subject to restri	/are withdrawn from cons					
Applicat	ion Papers						
9)	The specification is objected to by the	ne Examiner.					
10)	10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority (ınder 35 U.S.C. § 119						
a)	Acknowledgment is made of a claim All b) Some * c) None of: 1. Certified copies of the priority 2. Certified copies of the priority 3. Copies of the certified copies application from the Internationsee the attached detailed Office actions	documents have been reduced documents have been reduced of the priority documents onal Bureau (PCT Rule 1	eceived. eceived in Application Nos have been received in this 7.2(a)).				
Attachmen	ıt(s)						
2) Notice 3) Infor	te of References Cited (PTO-892) te of Draftsperson's Patent Drawing Review (mation Disclosure Statement(s) (PTO-1449 of No(s)/Mail Date <u>1</u> .	r PTO/SB/08) 5)	Interview Summary (PTO-413 Paper No(s)/Mail Date. Notice of Informal Patent App Other:	_ •			

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DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of Group 1, claims 1-5 and 8-18, is acknowledged.

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 1-5 and 8-18 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 1, line 10 contains the limitation of "optionally including...". Claim 1, line 40 contains the limitation of "optionally...". The scope of these claims are confusing as it is not understood if the "optional" limitations are required in order to read on the claims.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claims 1-5, 8-12, and 14-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 5,311,103).

Janesen teaches a method of roughening silicon substrates (column 6, lines 15-20) with diamond particles (column 6, line 30 - column 7, line 35). The nucleation density is within a range that would provide the claimed grain size (column 5, lines 30-50). Diamond is deposited on the substrate by plasma enhanced CVD (column 8, lines 15-29). The gasses, pressures, and temperatures are taught (column 7, line 55 - column 8, line 15). As the reference does not teach the inclusion of oxygen or nitrogen in the feed gases, and teaches that the amount of oxygen and nitrogen in the diamond film deposited should be minimized (column 11, lines 32-55), this reads on the gas being "essentially without oxygen or nitrogen" and the chamber being "essentially free from leaks of nitrogen or oxygen or mixtures thereof into the chamber". The reference fails to teach the inclusion of argon in the feed gas.

However, Desphandey teaches that argon has also been used with hydrogen and/or hydrocarbon gases to enhance the plasma volume chemistry in the region between the source and the substrate (column 5, lines 30-42). It would have been obvious at the time the invention was made to a person having ordinary skill in the art to use plasma in the gas feed of Janesen. By doing so, one would reap the benefits of enhanced plasma volume chemistry in the region between the source and the substrate. The combined references fail to teach performing the plasma CVD process in the claimed apparatus.

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However, Asmussen teaches an apparatus for depositing diamond films on silicon substrates (abstract). The apparatus reads on the applicant's claims (column 12, lines 7-47). The benefits of using the apparatus is that it is economical to construct and reliable to use and produces excellent results (column 5, lines 1-5). Additionally, the tunable features allow for efficient use, as extra plasma requiring extra power is not produced. It would have been obvious at the time the invention was made to a person having ordinary skill in the art to use the apparatus of Asmussen to perform the method of Janesen in view of Desphandey. By doing so, one would reap the benefits of efficient use, economical construction, reliable apparatus, and excellent results.

Claims 13 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 5,311,103), as applied to claims 1 and 2 above, and further in view of Herb et al. (US 5,273,790).

Janesen, in view of Desphandey and Asmussen, teaches the limitations of claims 1 and 2, as shown above, but fails to teach using molybdenum as the substrate holder. However, Herb teaches that the holder should be fabricated from materials chosen to exclude carbon, in order to eliminate a potential uncontrollable source of carbon. Materials suitable for use include molybdenum (column 6, lines 61-65). It would have been obvious at the time the invention was made to a person having ordinary skill in the art to utilize molybdenum as the substrate holder. By doing so, one would reap the benefits of preventing uncontrollable sources of carbon.

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Claims 1-5, 8-12, and 14-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 4,585,668).

Janesen, in view of Desphandey, teach the limitations above, but fail to teach performing the plasma CVD process in the claimed apparatus.

However, Asmussen teaches an apparatus that reads on the applicant's claims (column 13, lines 5-44). The benefits of using the apparatus is that it is economical to construct and reliable to use and produces excellent results (column 6, lines 60-68). Additionally, the tunable features allow for efficient use, as extra plasma requiring extra power is not produced (column 10, lines 29-35). It would have been obvious at the time the invention was made to a person having ordinary skill in the art to use the apparatus of Asmussen to perform the method of Janesen in view of Desphandey. By doing so, one would reap the benefits of efficient use, economical construction, reliable apparatus, and excellent results.

Claims 13 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 4,585,668), as applied to claims 1 and 2 above, and further in view of Herb et al. (US 5,273,790).

Janesen, in view of Desphandey and Asmussen, teaches the limitations of claims 1 and 2, as shown above, but fails to teach using molybdenum as the substrate holder.

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However, Herb teaches that the holder should be fabricated from materials chosen to exclude carbon, in order to eliminate a potential uncontrollable source of carbon.

Materials suitable for use include molybdenum (column 6, lines 61-65). It would have been obvious at the time the invention was made to a person having ordinary skill in the art to utilize molybdenum as the substrate holder. By doing so, one would reap the benefits of preventing uncontrollable sources of carbon.

Claims 1-5, 8-12, and 14-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 4,906,900).

Janesen, in view of Desphandey, teach the limitations above, but fail to teach performing the plasma CVD process in the claimed apparatus.

However, Asmussen teaches an apparatus that reads on the applicant's claims (column 10, lines 9-49). The benefits of using the apparatus is that it is economical to construct and reliable to use and produces excellent results (column 1, lines 59-68). Additionally, the tunable features allow for efficient use, as extra plasma requiring extra power is not produced. It would have been obvious at the time the invention was made to a person having ordinary skill in the art to use the apparatus of Asmussen to perform the method of Janesen in view of Desphandey. By doing so, one would reap the benefits of efficient use, economical construction, reliable apparatus, and excellent results.

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Claims 13 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 4,906,900), as applied to claims 1 and 2 above, and further in view of Herb et al. (US 5,273,790).

Janesen, in view of Desphandey and Asmussen, teaches the limitations of claims 1 and 2, as shown above, but fails to teach using molybdenum as the substrate holder. However, Herb teaches that the holder should be fabricated from materials chosen to exclude carbon, in order to eliminate a potential uncontrollable source of carbon. Materials suitable for use include molybdenum (column 6, lines 61-65). It would have been obvious at the time the invention was made to a person having ordinary skill in the art to utilize molybdenum as the substrate holder. By doing so, one would reap the benefits of preventing uncontrollable sources of carbon.

Claims 1-5, 8-12, and 14-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 4,727,293).

Janesen, in view of Desphandey, teach the limitations above, but fail to teach performing the plasma CVD process in the claimed apparatus.

However, Asmussen teaches an apparatus that reads on the applicant's claims (column 14, lines 5-44). The benefits of using the apparatus is that it is economical to construct and reliable to use and produces excellent results (column 1, lines 35-45).

Additionally, the tunable features allow for efficient use, as extra plasma requiring extra

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power is not produced. It would have been obvious at the time the invention was made to a person having ordinary skill in the art to use the apparatus of Asmussen to perform the method of Janesen in view of Desphandey. By doing so, one would reap the benefits of efficient use, economical construction, reliable apparatus, and excellent results.

Claims 13 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Janesen et al. (US 4,925,701), in view of Desphandey et al. (US 4,961,958), in further view of Asmussen et al. (US 4,727,293), as applied to claims 1 and 2 above, and further in view of Herb et al. (US 5,273,790).

Janesen, in view of Desphandey and Asmussen, teaches the limitations of claims 1 and 2, as shown above, but fails to teach using molybdenum as the substrate holder. However, Herb teaches that the holder should be fabricated from materials chosen to exclude carbon, in order to eliminate a potential uncontrollable source of carbon. Materials suitable for use include molybdenum (column 6, lines 61-65). It would have been obvious at the time the invention was made to a person having ordinary skill in the art to utilize molybdenum as the substrate holder. By doing so, one would reap the benefits of preventing uncontrollable sources of carbon.

Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the

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unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1-5, 8-12, and 14-17 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1, 2, and 4 of U.S. Patent No. 4,585,668 in view of Janesen et al. (US 4,925,701) in view of Desphandey et al. (US 4,961,958).

Claims 1, 2, and 4 of the patent teaches the applicant's claimed method steps, but fails to claim depositing diamond. Janesen, in view of Desphandey teaches a diamond deposition process that requires plasma CVD. It would have been obvious at the time the invention was made to a person having ordinary skill in the art to perform the diamond deposition of Janesen, in view of Desphandey, by the method of the U.S. Patent. By doing so, one would have a reasonable expectation of success, as the patent teaches a plasma deposition process and Janesen, in view of Desphandey, requires plasma deposition.

Claims 1-5, 8-12, and 14-17 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 22-27 of U.S.

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Patent No. 4,585,668 in view of Janesen et al. (US 4,925,701) in view of Desphandey et al. (US 4,961,958).

Claims 22-27 of the patent teaches the applicant's claimed method steps, but fails to claim depositing diamond. Janesen, in view of Desphandey teaches a diamond deposition process that requires plasma CVD. It would have been obvious at the time the invention was made to a person having ordinary skill in the art to perform the diamond deposition of Janesen, in view of Desphandey, by the method of the U.S. Patent. By doing so, one would have a reasonable expectation of success, as the patent teaches a plasma deposition process and Janesen, in view of Desphandey, requires plasma deposition.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eric B Fuller whose telephone number is (571) 272-1420. The examiner can normally be reached on Mondays through Thursdays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Shrive P Beck, can be reached at (571) 272-1415. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

EBF

TIMOTHY MEEKS BIMARY EXAMINER